

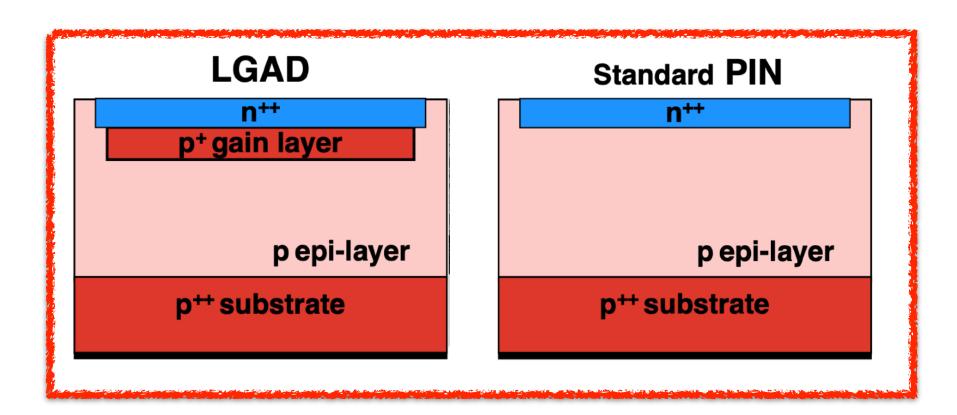
INTRODUCTION TO DEVICE CONSIDERED

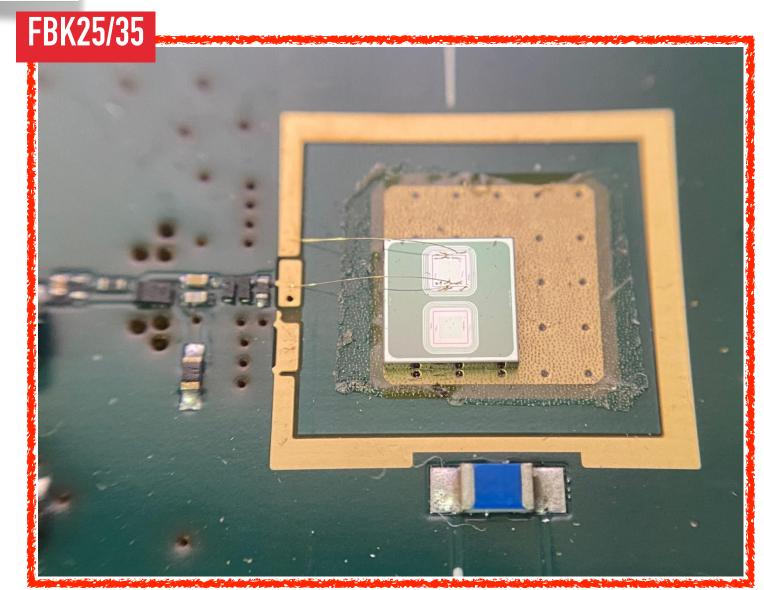
Study and characterization of LGAD: --

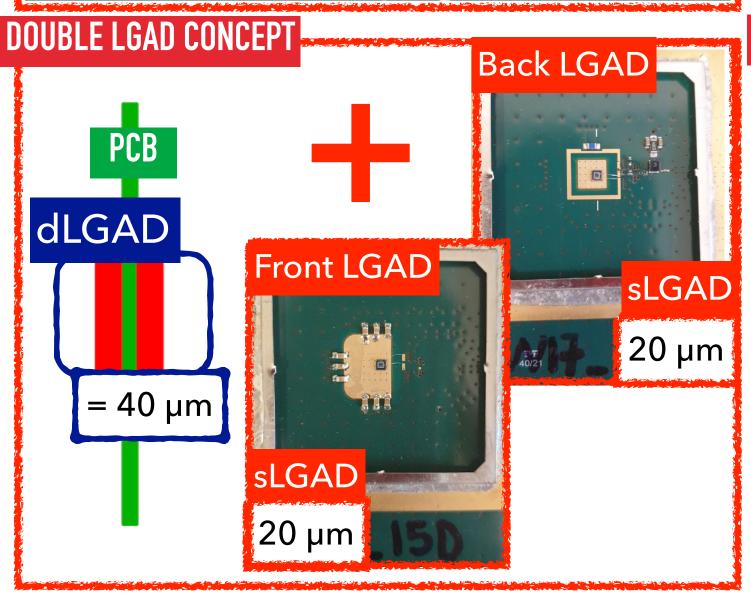
Single LGAD concept (sLGAD)

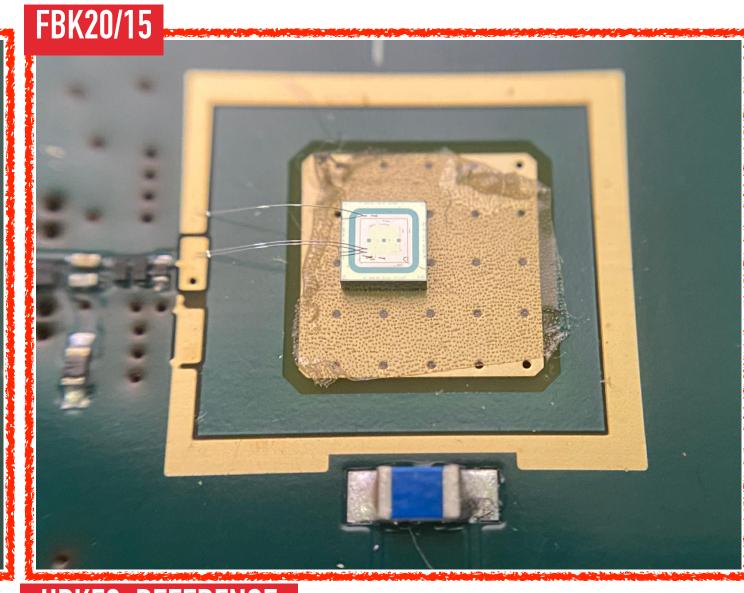
Double LGAD concept (dLGAD)

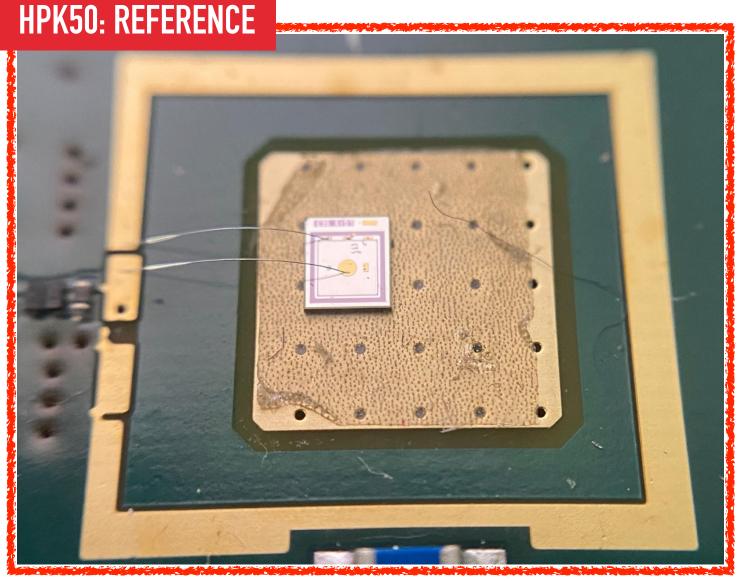
Thickness: 50-35-25-20-15 µm



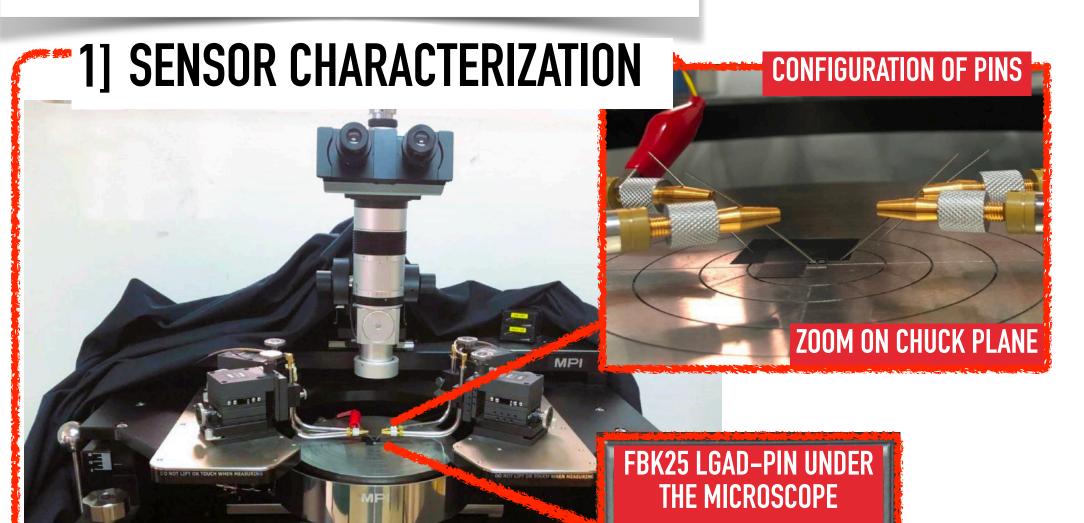


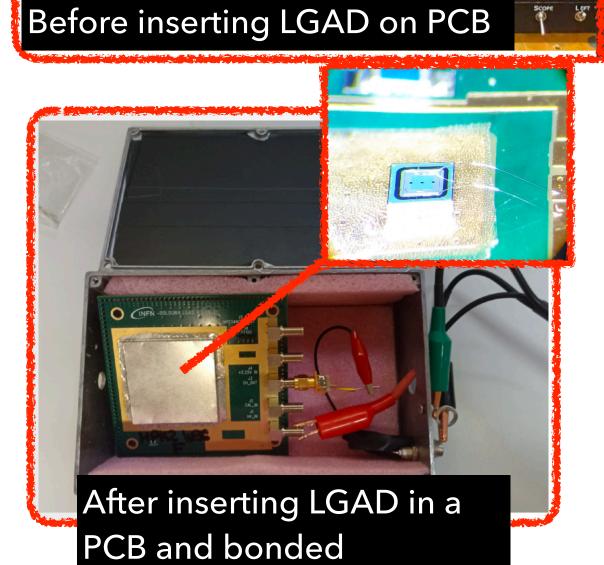


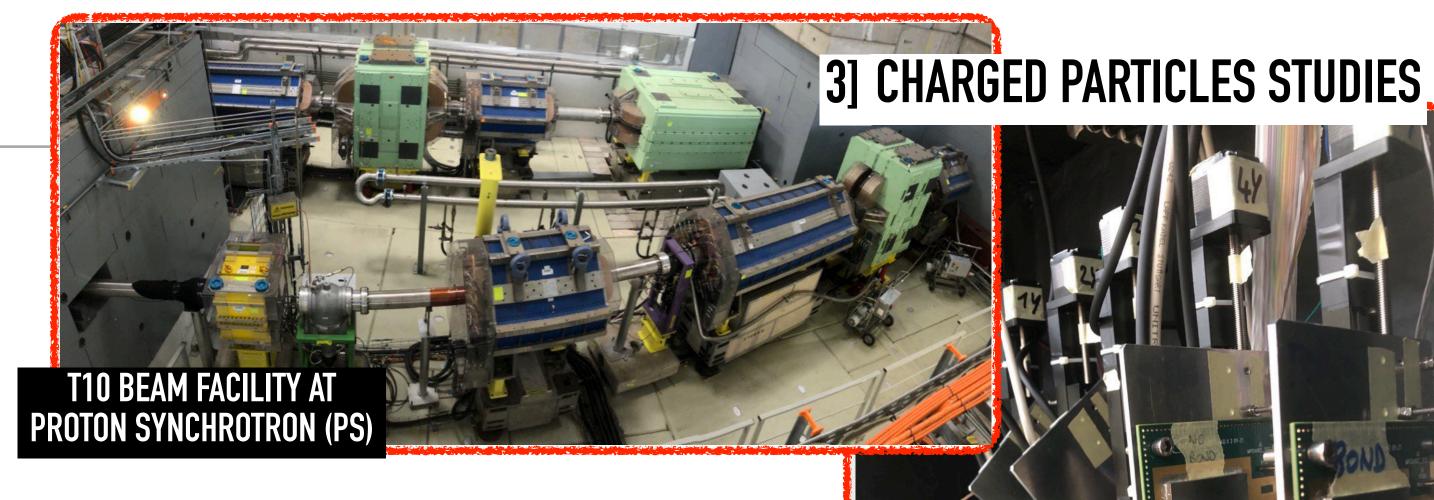




MY THESIS ACTIVITIES

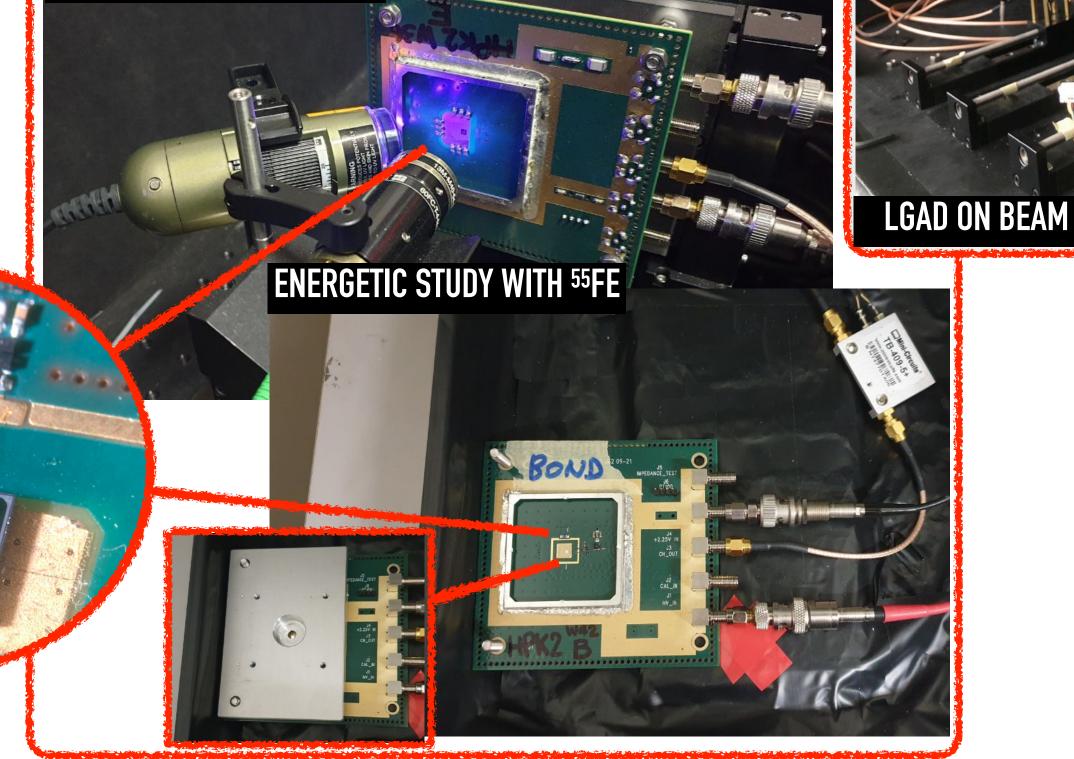






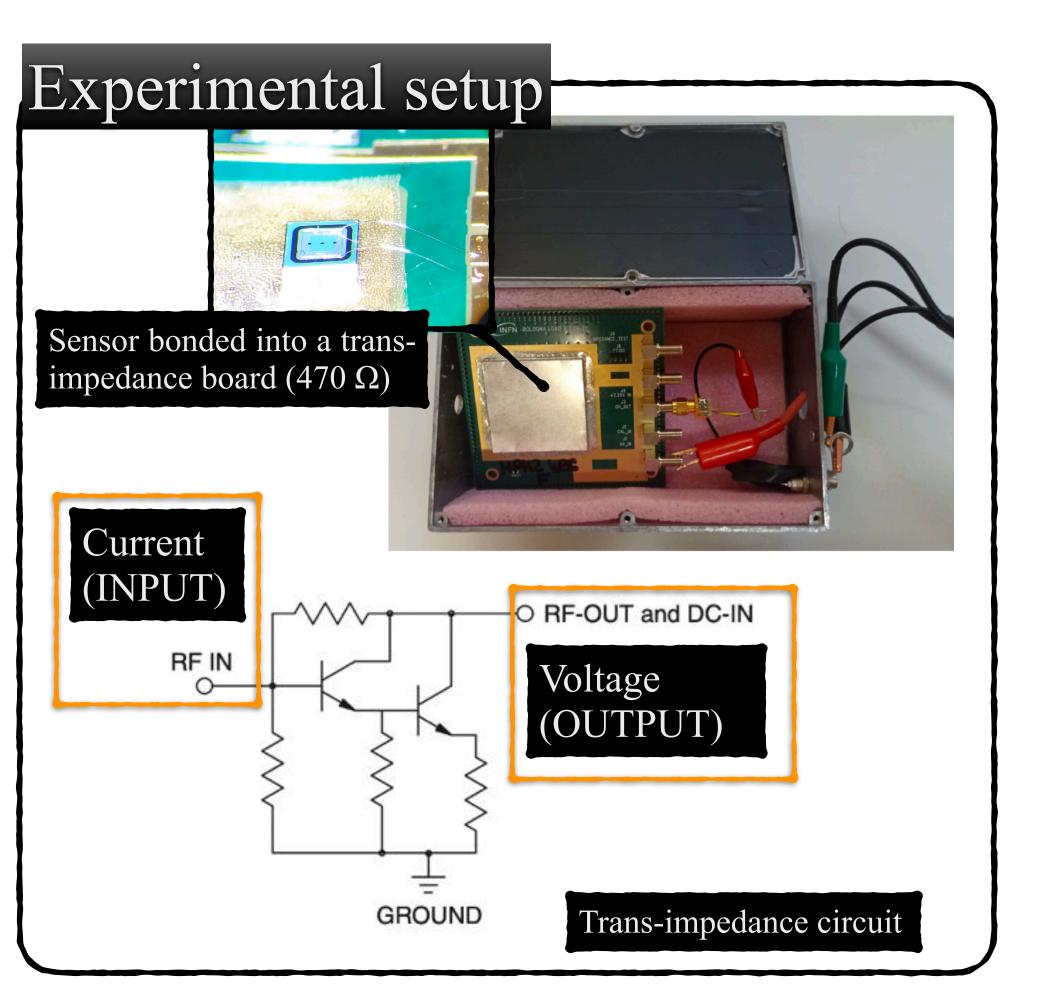
2] STUDIES WITH PHOTONS

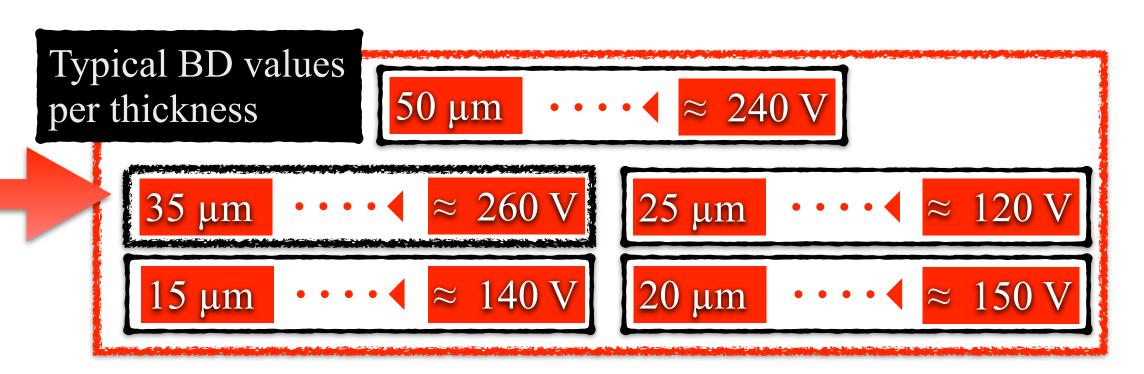
TIMING STUDY WITH LASER

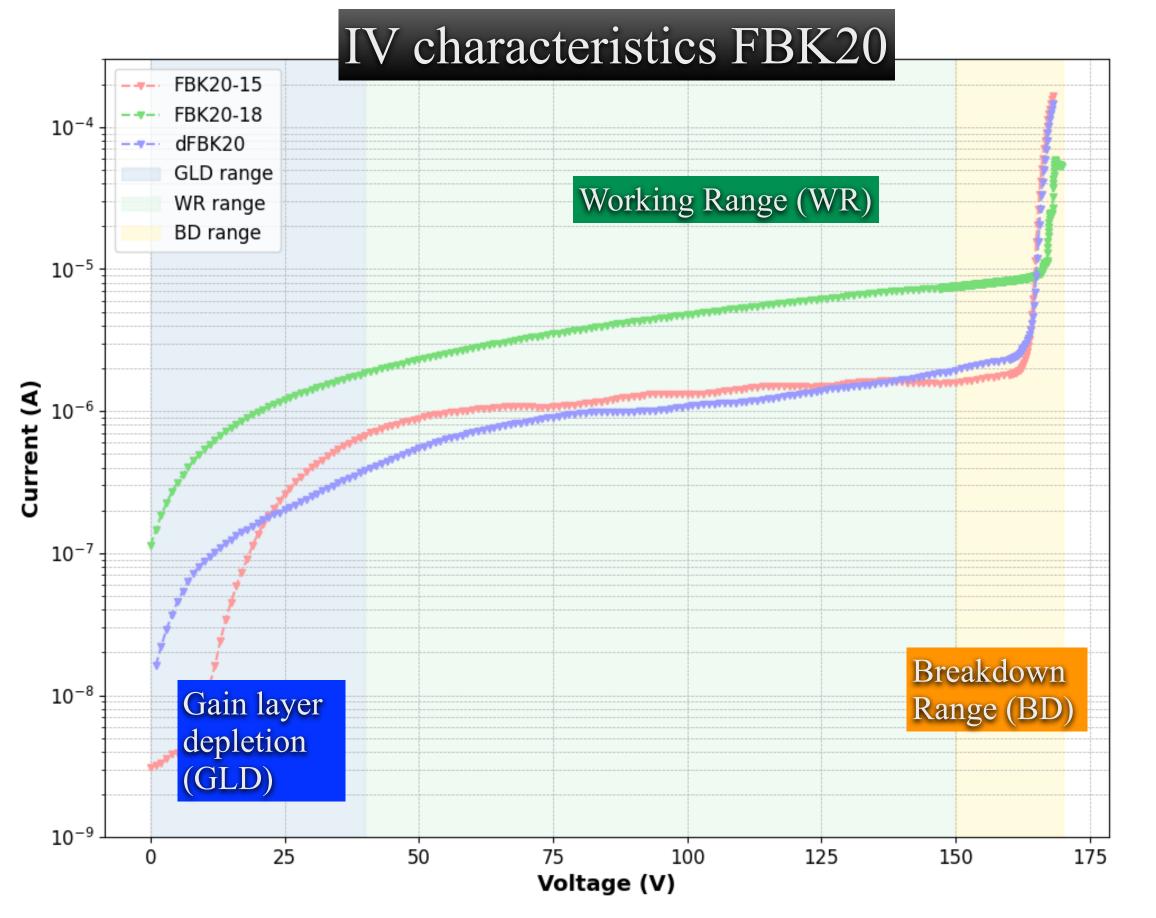


CHARACTERIZATION

- · · · ◆ Extraction of Breakdown value (BD)
- · · · ◀ Identification of Working Range (WR)

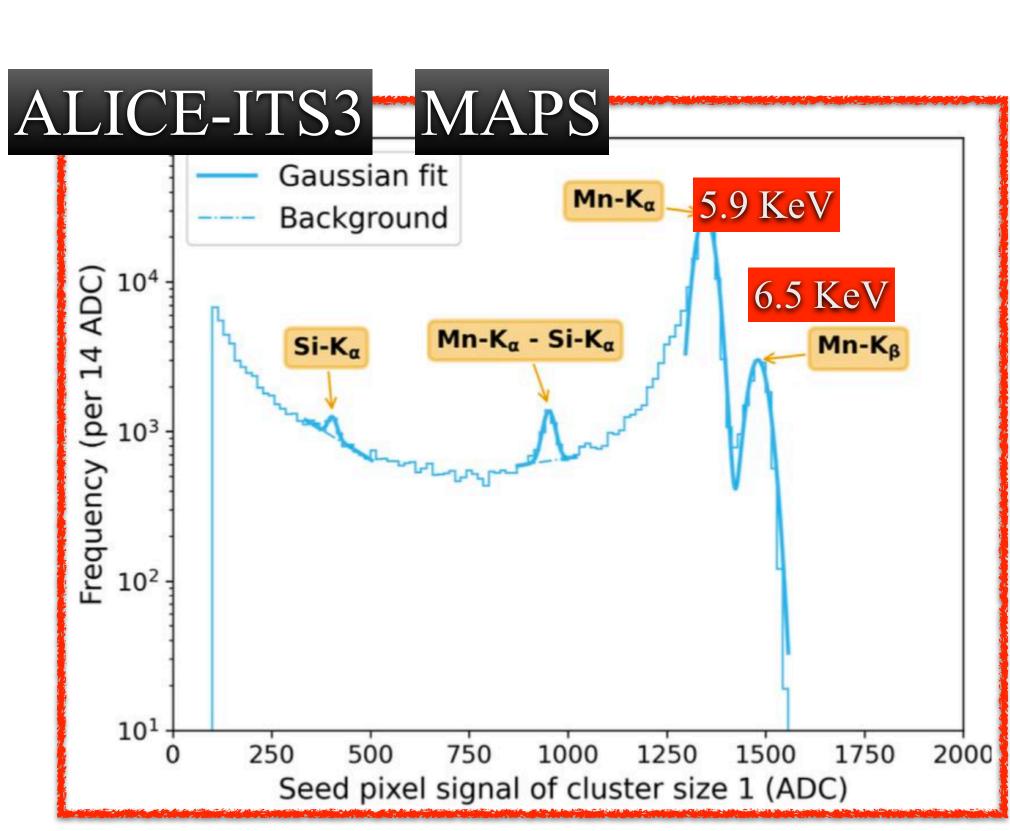




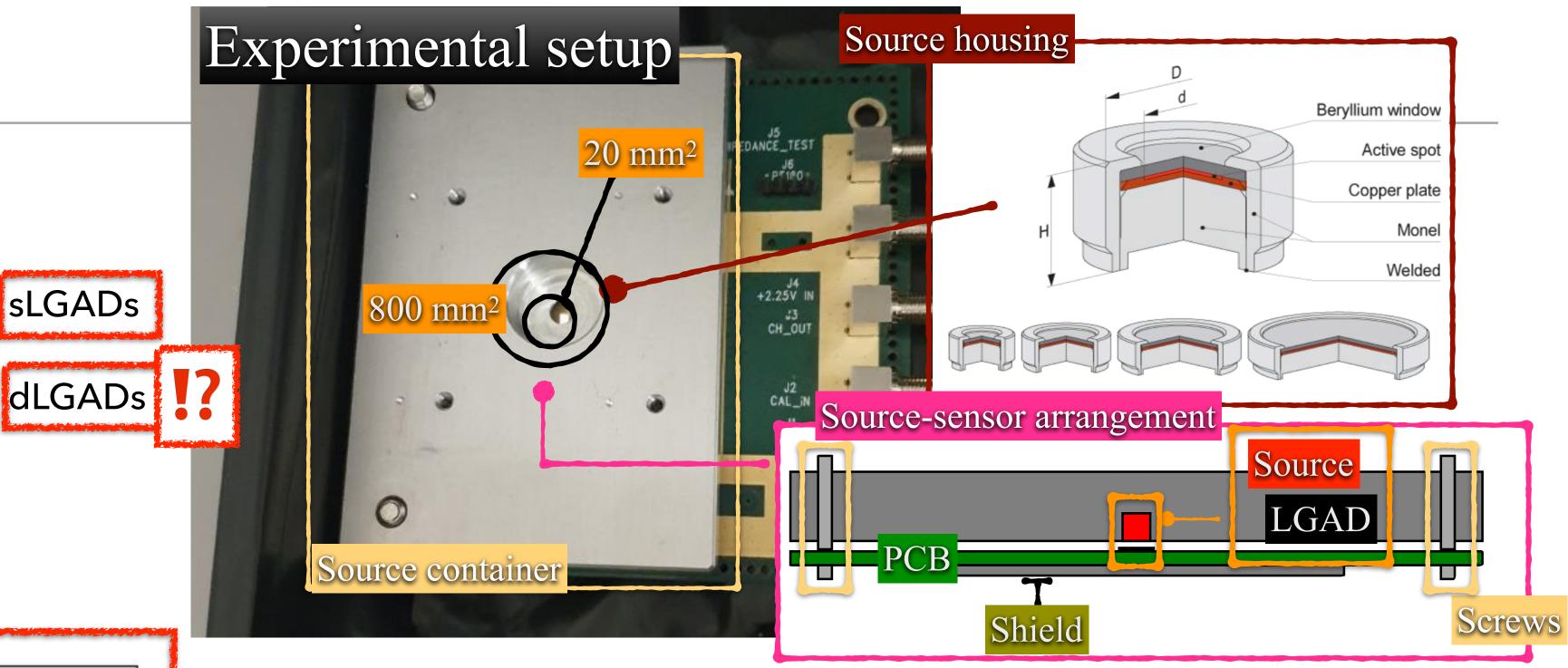


STUDY WITH 55FE

- Extract peak resolution
- Determine charge deposited
- Determine N_{eh}
- ◀ Extract S/N

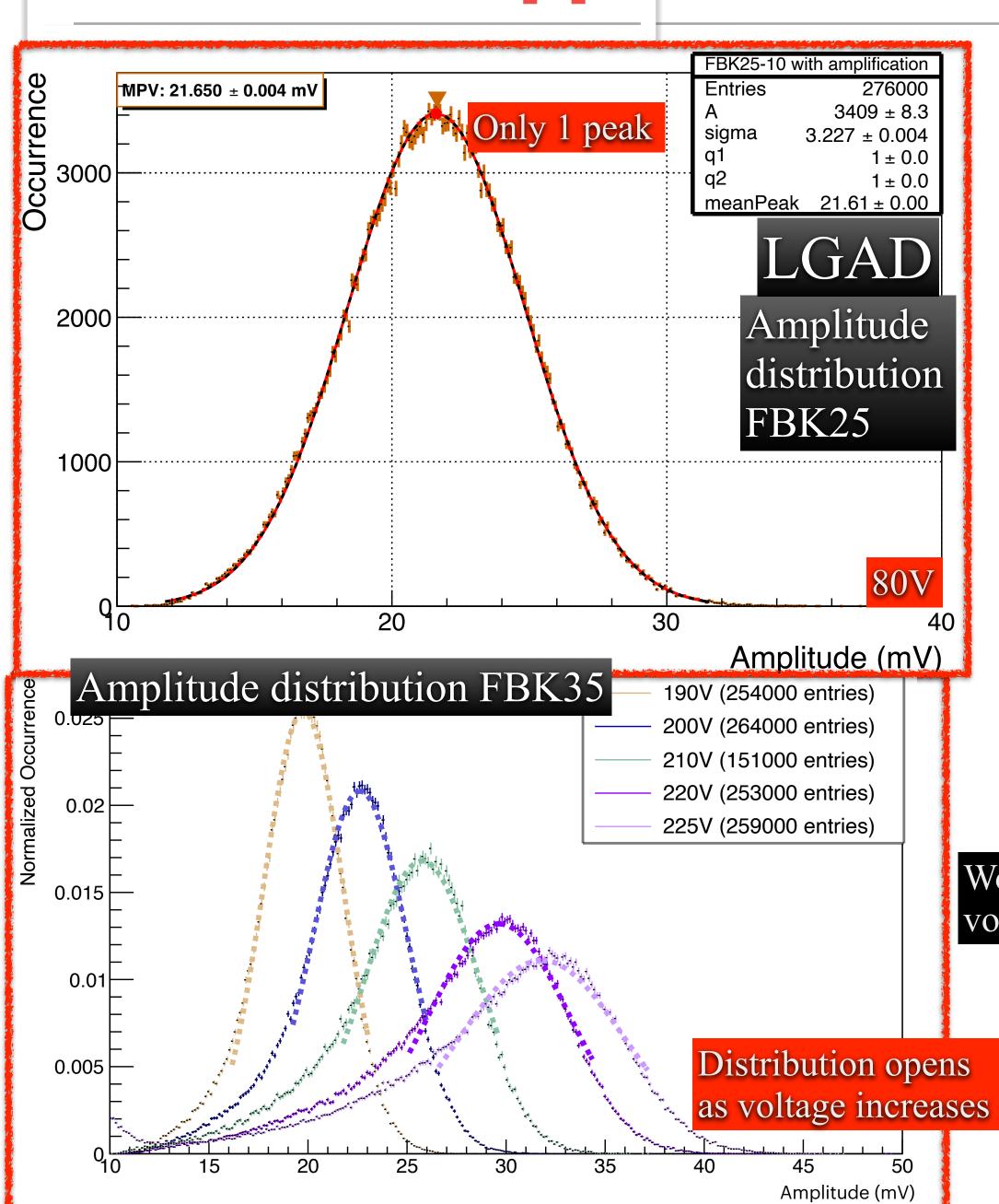


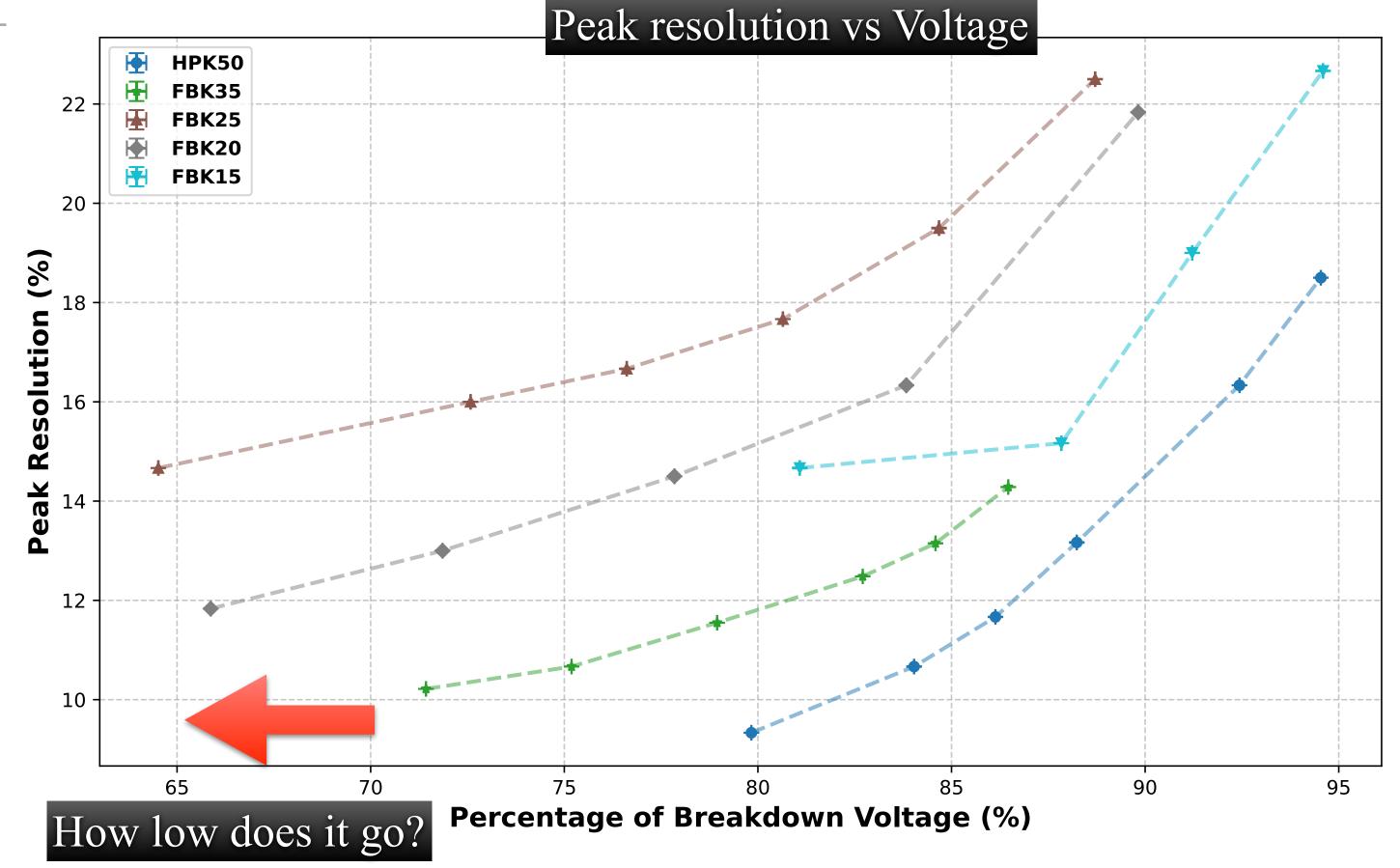
sLGADs



$^{55}Fe + e^{-}$	$\rightarrow^{55} Mn + \nu$	Energy (keV)	Emissions per 100 disint.
	Auger	0.47 - 0.67	140.2 (8)
	electrons	4.95 - 6.53	60.1(5)
		0.56 - 0.72	0.524 (21)
		5.888	8.45(14)
	X-rays	5.899	16.57(27)
		6.490	3.40(7)
		6.535	
	γ	125.959	$1.3 (1) \times 10^{-7}$

STUDY WITH 55FE [1]



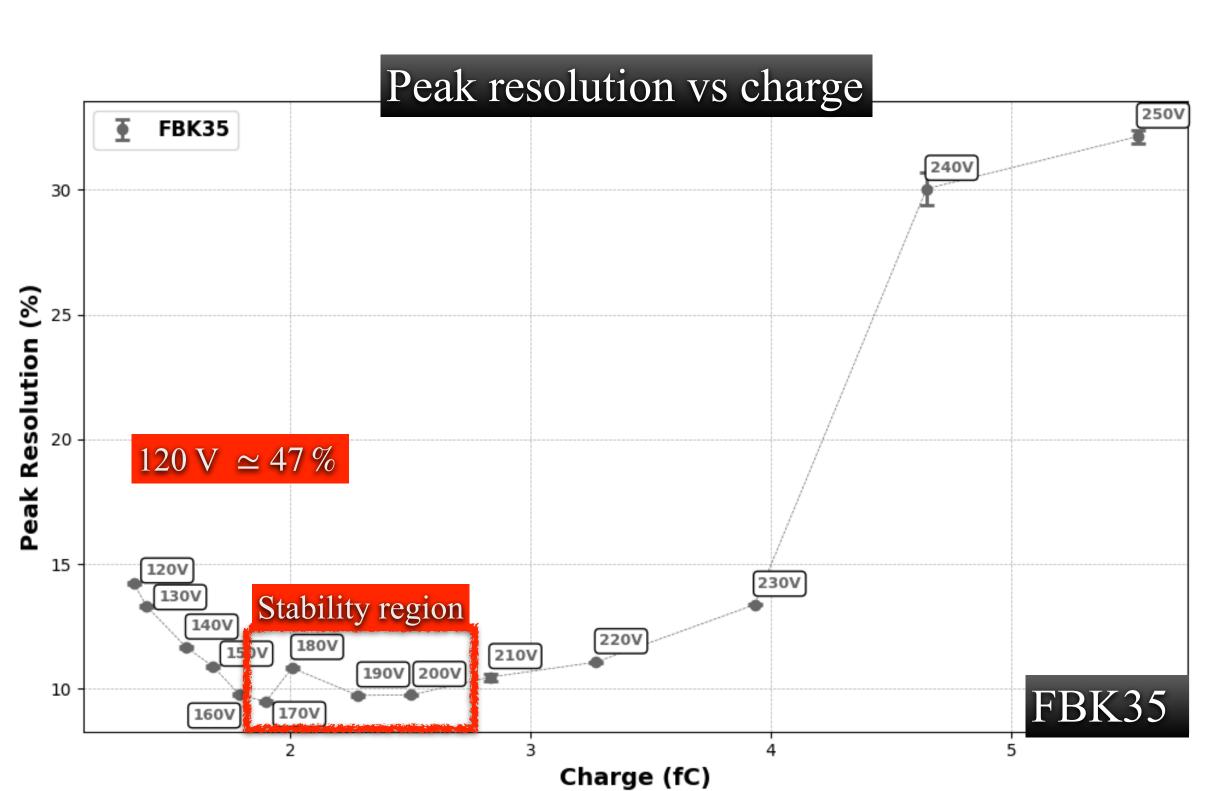


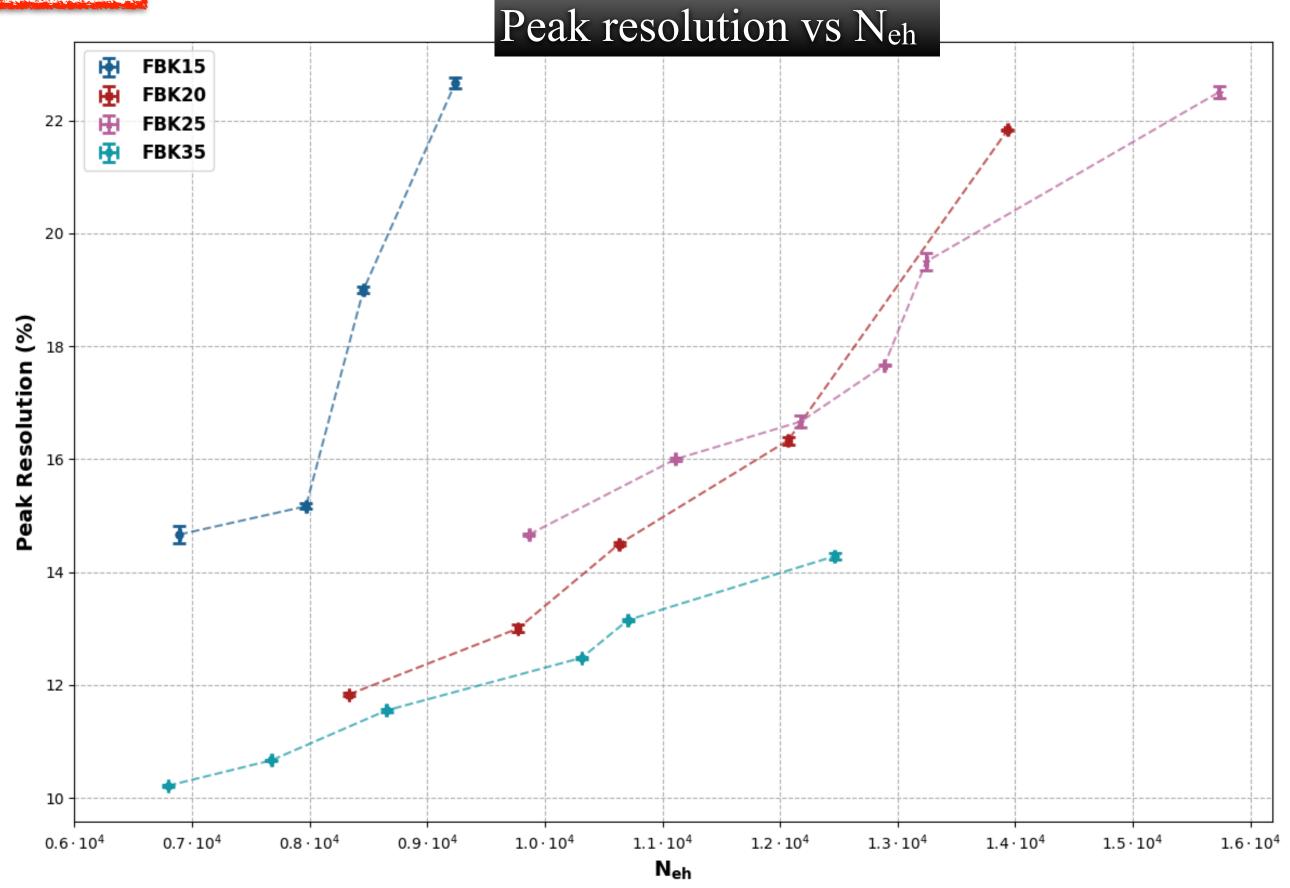
Worsening as
voltage increases

Voltage	Mean (mV)	Sigma (mV)
190	(19.76 ± 0.03)	(2.00 ± 0.06)
200	(22.62 ± 0.02)	(2.35 ± 0.04)
210	(25.76 ± 0.02)	(2.85 ± 0.05)
220	(29.64 ± 0.03)	(3.52 ± 0.08)
225	(31.88 ± 0.04)	(4.11 ± 0.02)

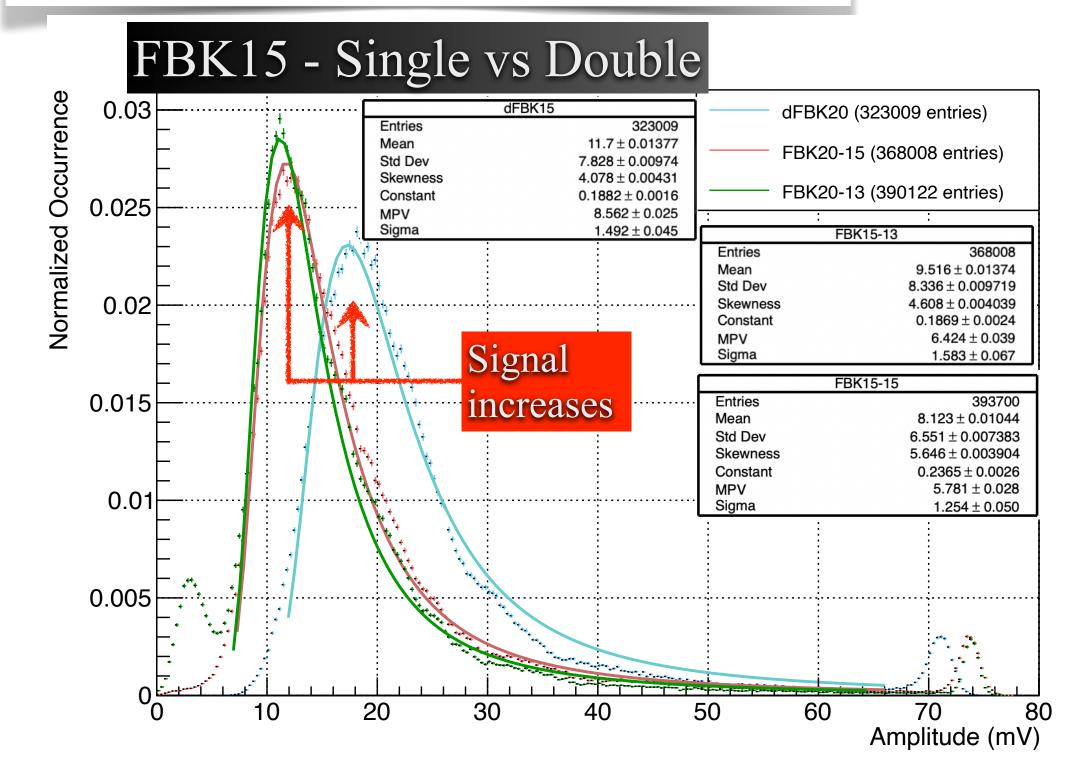
STUDY WITH 55FE [2]

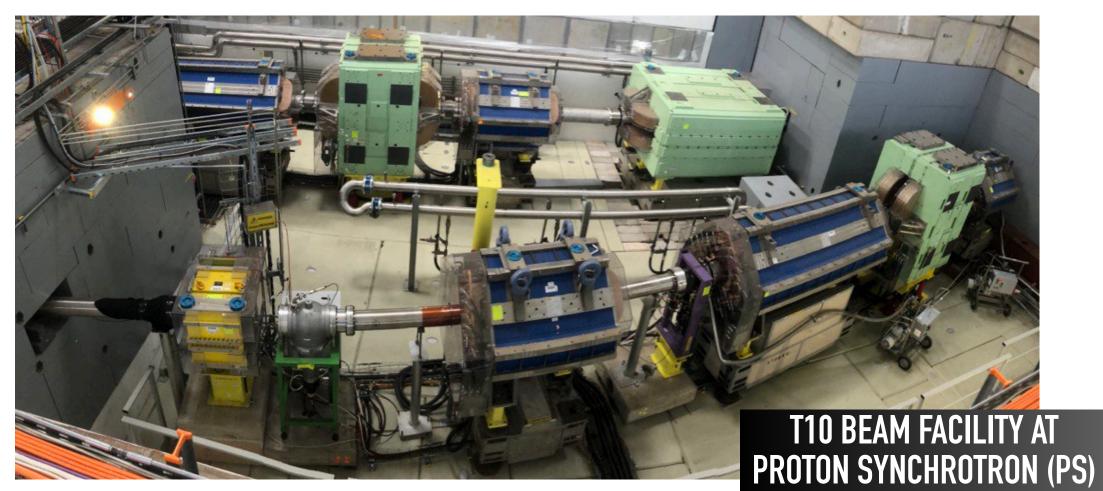
- ••• Difficult explore low voltage regime for thinner sensor
- · · ◆ Unreliable results FBK20-FBK15
- ••• Difficulty in comparing with HPK50 reference

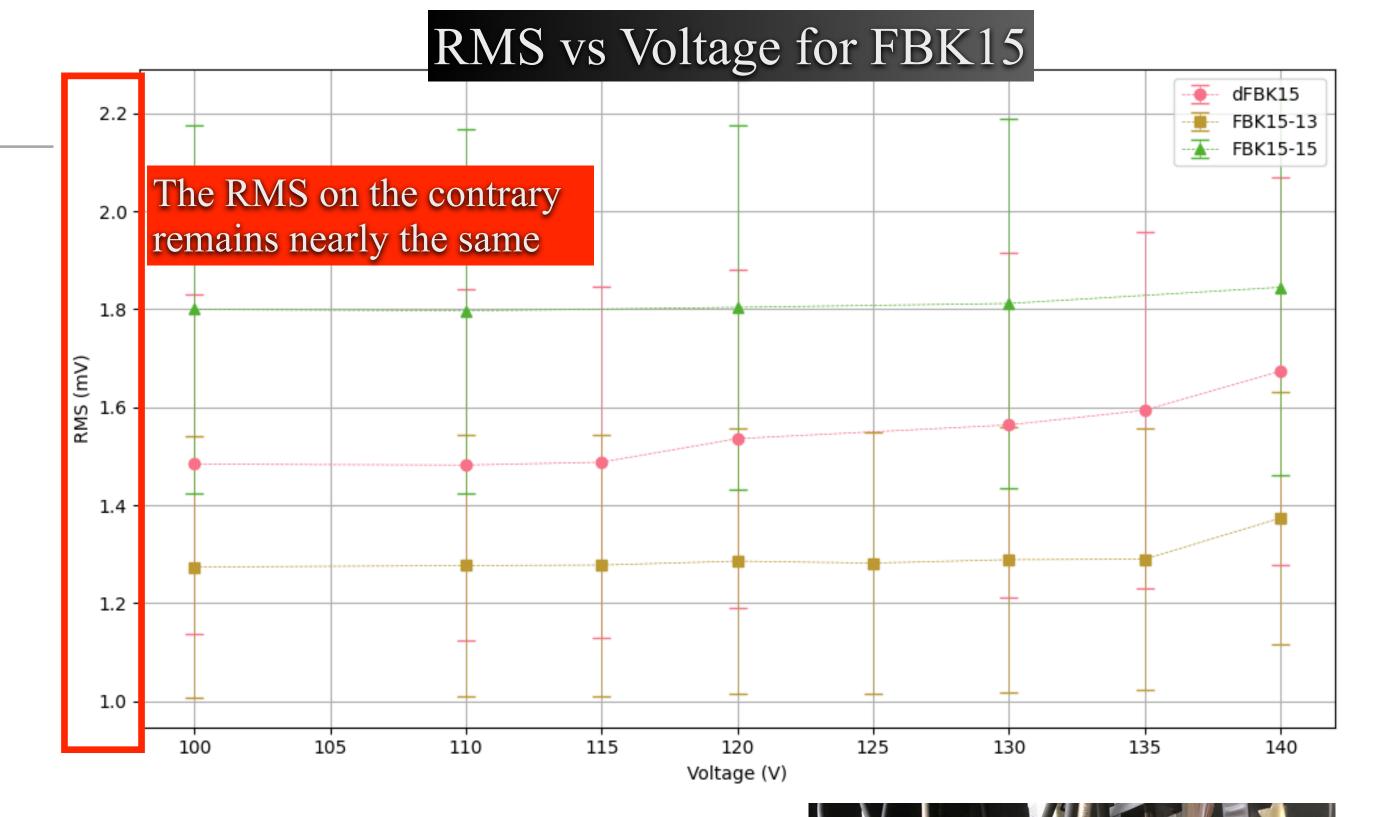


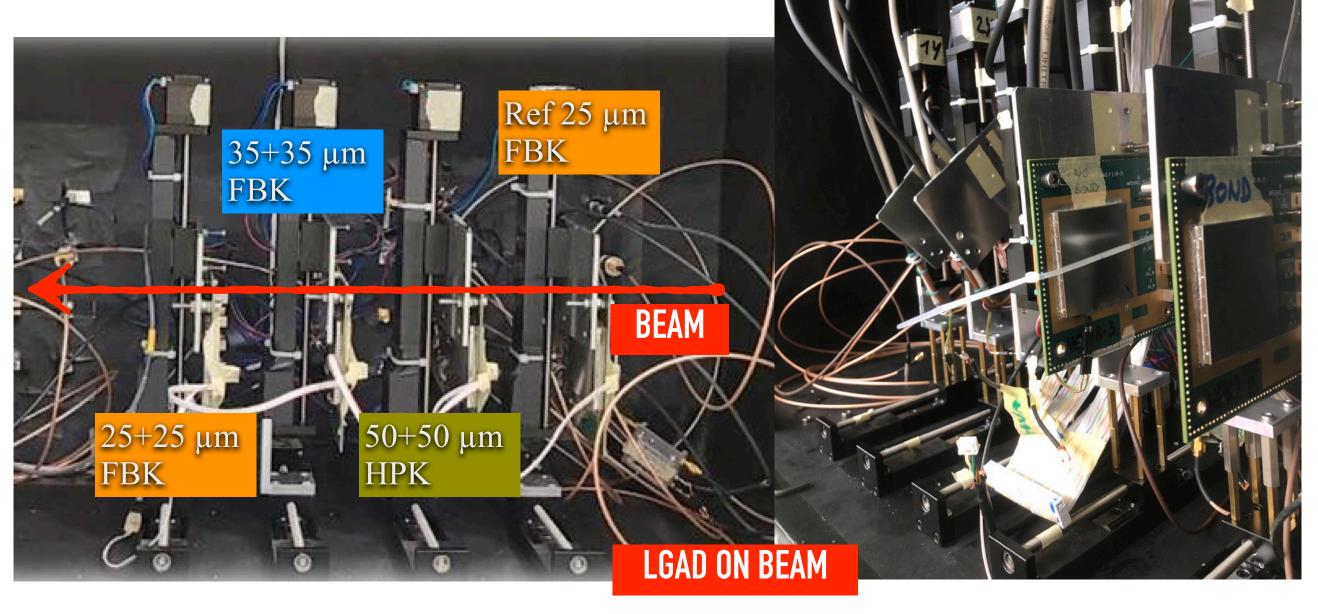


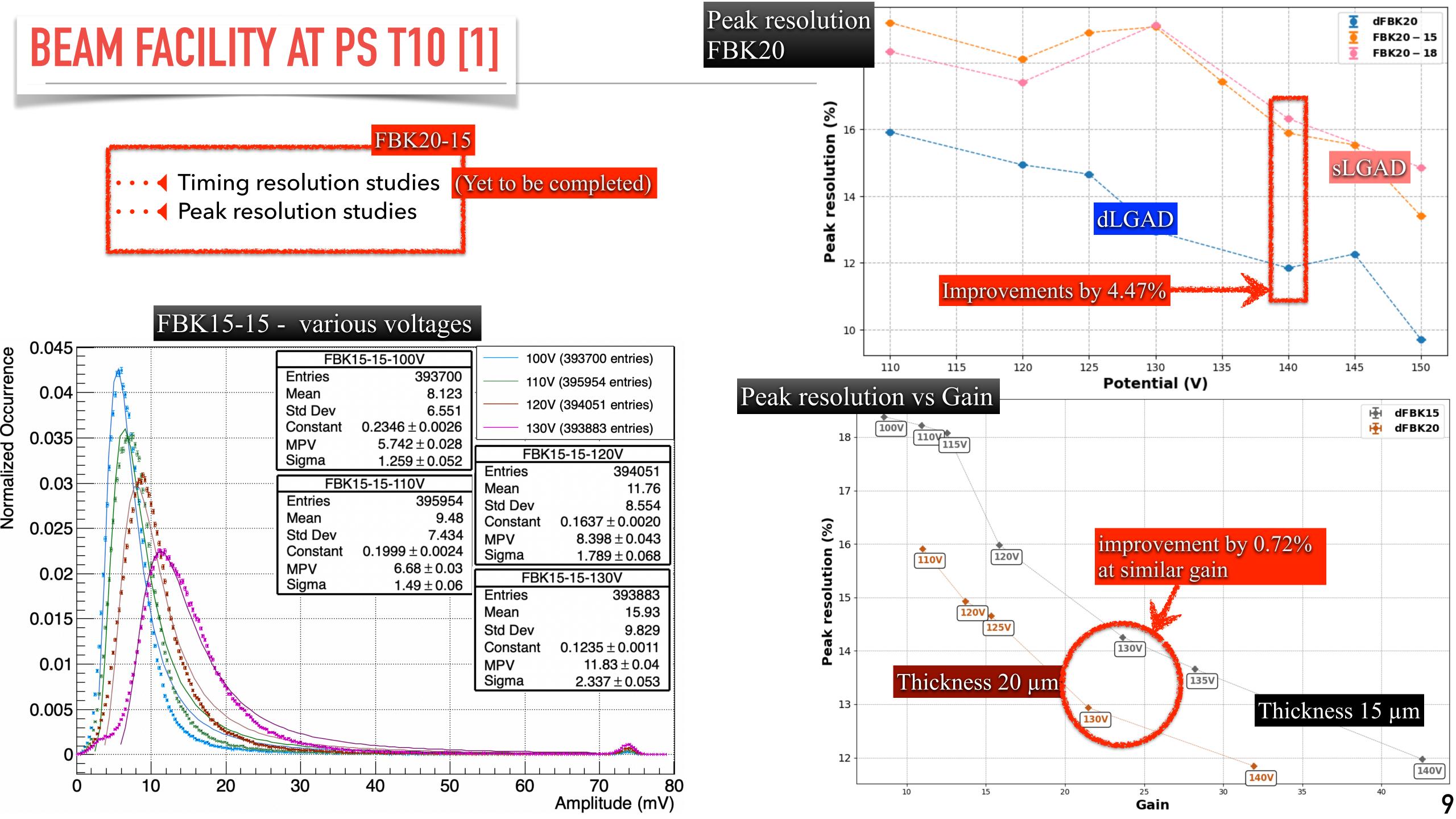
BEAM FACILITY AT PS T10











THEME OF MY PHD

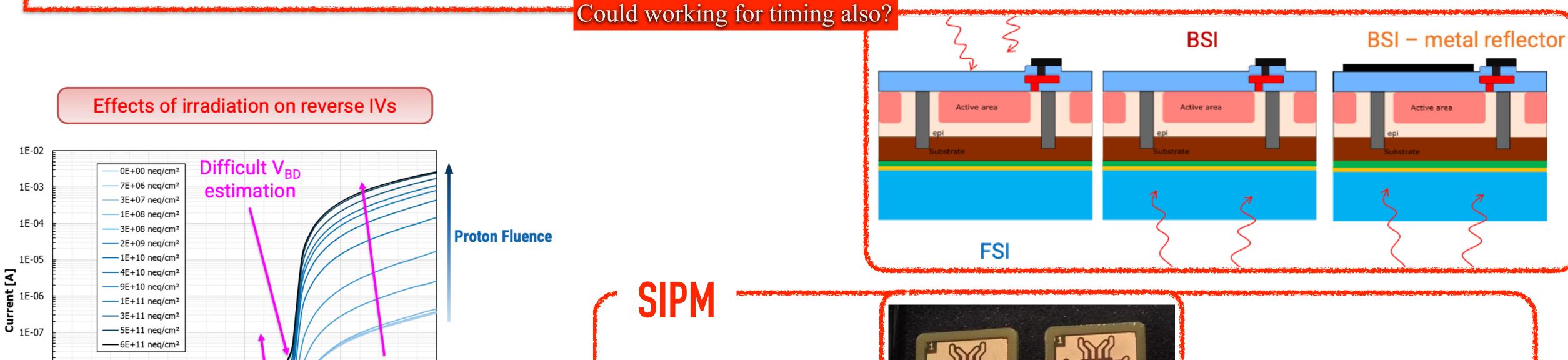
◀ Working on Silicon PhotonMultipliers (SiPM) and radiation damage

Increase of post-breakdown,

NUV-HD

CRYO, 40 µm cell

• • R&D for a radiation tolerant device for imaging application



Increase of pre-breakdown, nonmultiplied (~surface) current

30

Bias [V]

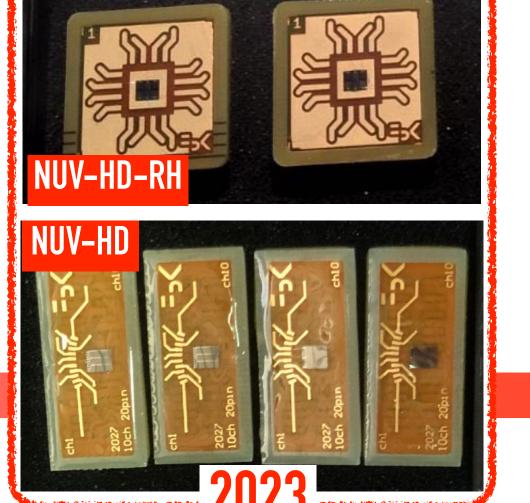
25

1E-08

1E-09

20







2024

